

Title (en)  
ELECTROLYTIC BATH

Title (de)  
ELEKTROLYTISCHES BAD

Title (fr)  
BAIN ÉLECTROLYTIQUE

Publication  
**EP 3099847 A1 20161207 (DE)**

Application  
**EP 14825092 A 20141124**

Priority  

- DE 102014100862 A 20140127
- DE 2014100412 W 20141124

Abstract (en)  
[origin: WO2015110099A1] The invention relates to an electrolytic bath for the deposition of glossy silver-nickel alloys onto substrates, consisting of an aqueous solution containing an ionic compound having a silver content of 15 to 30 g/l, preferably potassium silver cyanide, a nickel complex having a nickel content of 3 to 15 g/l, preferably tetracyanonickelate, and 10 to 20 g/l of potassium carbonate.

IPC 8 full level  
**C25D 3/46** (2006.01); **C25D 3/64** (2006.01)

CPC (source: EP)  
**C25D 3/46** (2013.01); **C25D 3/64** (2013.01)

Citation (search report)  
See references of WO 2015110099A1

Citation (examination)  

- EP 1690963 A1 20060816 - FURUKAWA ELECTRIC CO LTD [JP]
- S GLASSTONE ET AL: "THE ELECTRO-DEPOSITION OF SILVER FROM ARGENTOCYANIDE SOLUTIONS. PART II", 21 April 1931 (1931-04-21), pages 309 - 312, XP055397781, Retrieved from the Internet <URL:<http://pubs.rsc.org/en/Content/ArticlePDF/1931/TF/TF9312700309>> [retrieved on 20170810]

Designated contracting state (EPC)  
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

Designated extension state (EPC)  
BA ME

DOCDB simple family (publication)  
**WO 2015110099 A1 20150730**; DE 102014100862 A1 20150813; DE 102014100862 B4 20180208; EP 3099847 A1 20161207

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